compared to some of current interest.⁷ These results may also be relevant to puzzling differences reported between Ar matrix and organic glass photochemistry, as in the case of phenyl azide.32,33

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Supplementary Material Available: Spectral data for azo compounds 1, 5, 6, and 7 and the corresponding norbornadienones (2 pages). Ordering information is given on any current masthead page.

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Counterattack Reagent Hexamethyldisilane in the Direct Conversion of Aldehydes, Ketones, and Allyl Alcohols to Allyltrimethylsilanes

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Counterattack reagent¹ Me₃SiSiMe₃ can efficiently silylate hydrazines under alkaline conditions.² We intended to use the counterattack method to prepare another important class of compounds—allyltrimethylsilanes. The allyltrimethylsilane moiety is versatile in organic synthesis.³⁻⁸ This moiety possesses umpolung character and is regarded as a synthon for allyl cations and anions. Three new methods reported herein (see Scheme I) involve the use of Me₃SiSiMe₃ as a counterattack reagent; allyl alcohols, enals, enones, aldehydes, and ketones can be converted to allyltrimethylsilanes⁹ in one flask.

We treated an ether solution of allyl alcohols (1.0 equiv) with MeLi (1.5 equiv) at 0 °C and then added Me₃SiSiMe₃ (1.5 equiv) and hexamethylphosphoramide (HMPA, ether/HMPA = 1:4).



Scheme II



After ether was boiled off in situ under nitrogen, the reaction mixture was heated at 80 °C for 24 h. Aqueous workup followed by distillation provided the desired allylsilanes¹⁰ (Table I and Scheme I, method 1). Under these conditions, geraniol (1) gave allylsilanes 2 and 3^{9a} in 72% yield; linalool (4) afforded the same products (2 and 3) in 75% yield as well as a small amount of silyl ether 5 (5%); (-)-myrtenol (6) provided allylsilane 7 (65%) and silyl ether 8 (15%). When benzyl alcohol (9) was used as the starting material, the corresponding trimethylsilane 10¹¹ was obtained in only 30% yield. However we were able to convert a homobenzylic compound, phenylethyl alcohol (12), to (phenylethyl)silane 13 in 50% yield.

Method 2 in Scheme I illustrates a new method for the preparation of allyltrimethylsilanes¹⁰ from enals and enones by use of alkyllithium and Me₃SiSiMe₃. We treated acrolein (14, 1.0 equiv) sequentially with *n*-BuLi (1.2 equiv) and Me₃SiSiMe₃ (1.2 equiv) to give allylsilanes 15 and 16^{12} in 48% yield (15/16 = 5:1) as well as sec-silvl ether 17 in 10% yield. By use of the same procedure, methyl vinyl ketone (18) afforded allylsilanes 199b and 20 in 48% yield (19/20 = 3:1).

We found that the reaction of saturated aldehydes or ketones with vinyllithium (1.3 equiv) and Me₃SiSiMe₃ (1.3 equiv) also produced allyltrimethylsilanes¹⁰ (Table I and Scheme I, method 3). Thus 1-hexanal (21) gave allylsilanes 22 and 23 in 48% yield (22/23 = 5:1); 2-heptanone (25) afforded allylsilanes 26 and 27 in 66% yield (26/27 = 2:1); cyclohexanone (28) led to allylsilanes 29 in 75% yield.13

For the preparation of allyltrimethylsilanes by methods 1-3, the first step was to generate an allyl alkoxide: removal of the

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Table I. Allyltrimethylsilanes from Alcohols and Carbonyl Compounds by Methods 1-3 in Scheme I



proton from an allyl alcohol with MeLi in method 1; 1,2-addition of RLi to an α,β -unsaturated aldehyde or ketone in method 2; or addition of vinyllithium to a saturated carbonyl compound in method 3. The allyl alkoxide then reacted with Me₃SiSiMe₃ by a novel pathway to give allyltrimethylsilanes in situ; Scheme II shows a proposed mechanism with cyclohexanone and vinyllithium as the starting material.

Hexamethyldisilane was attacked by allyl alkoxide 30, generated by addition of vinyllithium to ketone 28, to give allyl trimethylsilyl ether 31 and $Me_3Si^{-,14}$ Leaving group Me_3Si^{-} then counterattacked intermediate 31 by an $S_N 2'$ pathway to produce the corresponding allyltrimethylsilane 29 and Me_3SiO^- . In the counterattacking step (i.e., $31 \rightarrow 29$), a strong C–O bond (86 kcal/mol) in 31 was cleaved and a weak Si-C bond (72 kcal/mol) in 29 was formed.¹⁵ However highly unstable species Me₃Si⁻ was consumed and more stable anion Me₃SiO⁻ was generated. Therefore conversion of 31 to 29 was a thermodynamically favorable process.



In the entire pathway shown in Scheme II, Me₃SiSiMe₃ behaved as a counterattack reagent.

Each of the methods 1-3 involved an allyl trimethylsilyl ether as the intermediate. In the reactions with 4, 6, 9, 14, and 21 as the starting material, we were able to detect silvl ethers 5, 8, 11, 17, and 24, respectively, in the crude reaction products.

We attempted to prepare a cyclic allyltrimethylsilane from a cyclic allyl alcohol (32) by method 1 after having had success in primary allyltrimethylsilanes. Nevertheless we obtained only

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vinyltrimethylsilane 33 (65%) and aromatized product 34 (7%). When employing the conditions of method 2 ($R^2Li = MeLi$) to 2-cyclohexen-1-one (35), we also isolated the corresponding vinyltrimethylsilane 36 as the major product (36%). The desired allyltrimethylsilane 38 was obtained in 15% yield; other minor products included aromatic silane 37 (15%) and trimethylsilyl ether **39** (5%).

In conclusion, use of the counterattack method facilitated the preparation of allyltrimethylsilanes. Treatment of the readily available starting material, allyl alcohols, enals, enones, aldehydes, or ketones with organolithium reagents gave allyl alkoxides. The alkoxides then reacted with Me₃SiSiMe₃ to afford trimethylsilyl ethers and Me₃Si⁻. In situ a substitution reaction occurred between these two species to produce allyltrimethylsilanes in good yields. In these one-flask reactions, Me₃SiSiMe₃ behaved as a counterattack reagent.

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Electronic Properties and Redox Conduction of Ferrocene-Substituted High Polymeric Phosphazenes

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We have recently reported on the electronic properties of phosphazene substituents which affect thermodynamic shifts in the oxidation peak potential of ferrocene.¹ Examination of the electrochemistry of ferrocene bonded to phosphazenes provides a direct probe of the electronic and bonding structure of this important class of molecules. In this paper we present the first thermodynamic and kinetic data obtained for the electrochemical oxidation and reduction of ferrocene-substituted polyphosphazenes $[N_3P_3F_4(\eta-C_5H_4)_2Fe]_n$ (I), $[N_3P_3(OCH_2CF_3)_5(\eta-C_5H_4)Fe(\eta-C_5H_5)]_n$ (II), and $[N_3P_3(OCH_2CF_3)_4(\eta-C_5H_4)_2Fe]_n$ (III).

Cyclic voltammetry and chronoamperometry at platinum disk electrodes (radius = 1.9 mm) coated with evaporatively deposited (from DMF) polymers were used to study electron transfer and cross exchange processes. Voltammograms for a surface immobilized film of I in dichloromethane are shown in Figure 1A. Voltammetry of I in acetonitrile solutions results in irreproducible electrochemistry and deterioration of the polymer film apparently due to a chemical reaction of oxidized I with acetonitrile. Electrochemistry in dichloromethane is reproducible and can be used to ascertain the thermodynamic properties of this polymer. The surface coverage of the polymer (Γ) was obtained by integrating the area under the oxidation wave.²

The large difference between oxidation and reduction peak potentials (ΔE_p) and asymmetrical peak shapes are typical of the voltammetry obtained with platinum electrodes modified with polymer films of I. The separation between voltammetric peaks



Figure 1. Cyclic voltammograms of evaporatively deposited polyphosphazenes I (A), II (B), and III (C), on Pt electrodes, in 0.1 M tetrahexylammonium perchlorate/dichloromethane (A) or 0.1 M tetraethylammonium perchlorate/acetonitrile (B and C). Scan rates: 0.2 (a), 0.1 (b), 0.05 (c), 0.02 (d), 0.01 (e) V/s. Surface coverage $\Gamma = 4.9 \times 10^{-8}$ mol/cm^2 (A), 1.6 × 10⁻⁹ mol/cm² (B), and 4.8 × 10⁻⁹ mol/cm² (C).

Table I. Charge Transport Rates of Ferrocene-Substituted Polyphosphazenes^a

compd	$(D_{ct}^{1/2}C)_{anod}^{b,c}$ $(10^{-8} \text{ mol/cm}^2)$	$(D_{ct}^{1/2}C)_{cath}^{c}$ $(10^{-8} \text{ mol/cm}^2)$
I ^d	1.41 (±0.15)	1.52 (±0.24)
II	1.96 (±0.18)	$1.81 (\pm 0.44)$
III	3.20 (±0.20) ^e	6.19 (±1.65)
III	7.49 (±0.71)	

"The preanalysis potential was held at either 0.0 or 1.0 V for II and 1.3 V for III for at least 60 s prior to the application of the forward (oxidation) or reverse (reduction) potential step, respectively, to assure a homogeneous film oxidation state and to eliminate effects from insufficient film oxidation or reduction as an initial condition. bn = 18for all averages except I (n = 5) and $(D_{ct}^{1/2}C)_{anod}$ for II (n = 21). ^cValues in parentheses represent the 95% confidence interval. ^dValues for this polymer calculated with the Randles-Sevcik equation. "Values obtained between 10 and 25 ms. ^fValues obtained between 25 and 50 ms.

ranges from a low of 0.26 V at a 10 mV/s scan rate to a high of 1.24 V at a 200 mV/s scan rate. Plots of $(i_p)_{anod}$ versus square root of scan rate $(v^{1/2})$ were linear (correlation coefficient = 0.9965, n = 5) for values between the scan rate limits examined.

The linear relationship between $(i_p)_{anod}$ and $v^{1/2}$ indicates that charge transfer is similar to a semi-infinite linear diffusion process as described by the Randles-Sevcik equation.³ Rates for charge transport $(D_{ct}^{1/2}C)$ for I are listed in Table I. The large variation of peak potentials with scan rate suggests that the polymer film undergoes a chemical reaction following the oxidation of ferrocene. This result is similar to the voltammetry observed for its low molecular weight analogue $N_3P_3F_4(\eta-C_5H_4)_2Fe^{.1}$ The oxidized and chemically rearranged phosphazenyl ferrocene is reduced at

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